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# X-ray standing wave study of CdTe/MnTe/CdTe(001) heterointerfaces

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The x-ray standing wave method is used to investigate some crystallographic features of the first stages of growth of ultrathin pseudomorphic MnTe(001) strained layers buried in CdTe on CdTe(001) substrates. Experiments with 004 and 113 reflecting planes show evidence of the presence of both MnTe clusters and diluted CdMnTe alloy.  
[0]

## I. INTRODUCTION

The physical properties of semiconductor strained heterostructures are strongly dependent on the morphology of interfaces (abruptness and roughness) and on the presence of faults (dislocations, twins, etc.). Complementary studies are necessary to identify how a given interface can deviate from a perfect one, due to segregation,<sup>1</sup> to interdiffusion after the growth of the interface,<sup>2</sup> or during its growth itself,<sup>3</sup> or to the existence of two dimensional (2D) or 3D islands reflecting the surface morphology when switching the molecular beams on or off.<sup>4</sup> The lateral scale of these deviations is a key parameter, and each experimental method will check the interface at different characteristic length scales. For example, for optical studies of excitons confined in a quantum well,<sup>4</sup> the lateral scale is defined by the coherence length of the exciton, and the interface will be called smooth if it exhibits only 2D islands, 1 monolayer thick, wider in the interface plane than the exciton size. If these islands are of the order of the exciton size, the interface is called rough since this size island gives rise to a broadening of the exciton optical line due to thickness fluctuations of the quantum well. If the lateral scale is even smaller, however, these fluctuations are averaged out and the line is sharp again; then the interface is called pseudo-smooth. These different morphologies have been clearly identified in III–V quantum wells grown under various conditions. The x-ray standing wave (XSW) method is well known to be very sensitive to the position and the order (or disorder) of very thin layers (less than a monolayer to several monolayers).<sup>5–8</sup> We report here on the application of this method to ultrathin MnTe layers grown in CdTe (001) by molecular beam epitaxy. The results will be compared to high resolution transmission electron microscopy (HRTEM) of MnTe layers in CdTe (see Ref. 9) and to a magneto-optic study (enhanced Zeeman effect) of CdTe-CdMnTe quantum wells.<sup>3</sup>

In the following sections we describe the XSW method and the experimental setup; the results are reported in Sec. III and discussed in Sec. IV.

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## A. Principle of the x-ray standing wave method

The XSW method is used to determine the localization of atoms in volume or on a surface. According to x-ray dynamical theory,<sup>5–7</sup> the interaction between the x-ray and a crystal leads to the following result: when the crystal is at a Bragg diffraction position, interferences occur between the incident and the diffracted beam leading to a standing wave field with nodal and antinodal planes parallel to the diffracting planes,  $hkl$ , and having the same period,  $d_{hkl}$ . When the crystal is rocked through the reflection domain, from lower to higher angles, the positions of the node and antinode planes are shifted inwards by  $d_{hkl}/2$ . Thus, the fluorescence yield of atoms, which depends on the intensity of the x-ray standing wave field, is very sensitive to the atom position. An XSW experiment consists of simultaneously recording the rocking curve and the fluorescence yield of “impurity” atoms (here a thin buried layer). It determines the position of atoms with respect to the bulk diffracting planes with a good precision, typically within several hundredths of Å. The information is along the normal to the diffracting planes: when they are parallel to the interface (or the surface), an XSW experiment gives the vertical position of atoms above the interface; with tilted reflections [like 220 for a (100) surface], it gives lateral information (see Ref. 10 for details).

### 1. Fluorescence yield and structure

The normalized fluorescence yield is given by (see Ref. 8 and references therein):

$$Y(\Theta) = 1 + |\xi(\Theta)|^2 + 2|\xi(\Theta)|F_{hkl} \cos[\psi(\Theta) - 2\pi P_{hkl}], \quad (1)$$

where  $|\xi(\Theta)|^2$  is the reflectivity and  $\Psi(\Theta)$  the phase of the reflected wave. The  $P_{hkl}$  and  $F_{hkl}$  parameters are, respectively, called the coherent position and the coherent fraction. These are related to the Fourier component, with respect to the  $\mathbf{h}$  diffraction vector, of the atomic distribution,  $\rho(z)$ ,

along the normal to the diffracting planes (defined with the  $\mathbf{n}_{hkl}$  vector):

$$F_{hkl} e^{i2\pi P_{hkl}} = \frac{\int \rho(z) e^{i2\pi \mathbf{n}_{hkl} z} dz}{\int \rho(z) dz} = \frac{\int \rho(z) e^{i2\pi z/d_{hkl}} dz}{\int \rho(z) dz}. \quad (2)$$

$$F_{hkl} = (1 - D_{SD}) \sqrt{\left[ \sum_i f_{hkl}^i \sin(2\pi P_{hkl}^i) \right]^2 + \left[ \sum_i f_{hkl}^i \cos(2\pi P_{hkl}^i) \right]^2} \quad (3)$$

and

$$\tan(2\pi P_{hkl}) = \frac{\sum_i f_{hkl}^i \sin(2\pi P_{hkl}^i)}{\sum_i f_{hkl}^i \cos(2\pi P_{hkl}^i)}, \quad (4)$$

where  $P_{hkl}^i$  is the ‘‘average’’ coherent position of the  $i$  site (perpendicularly to the  $hkl$  plane). Since the value of the coherent position,  $P_{hkl}$ , is given modulo 1, we will choose, in the following parts, the  $P_{hkl}$  value in the  $[-0.5, 0.5]$  interval. When it is necessary, we will introduce the physical position (divided by  $d_{hkl}$ ), called  $D_{hkl}$ , deduced from  $P_{hkl}$ . We have the relation  $D_{hkl} = P_{hkl} + m$ , where  $m$  is an integer number.  $(1 - D_{SD})$  is the random static disorder, which takes into account the percentage of studied atoms which are quasi-randomly distributed, i.e., which cannot be reduced to one average position. The  $f_{hkl}^i$  factor takes into account the disorder, some crystallographic characteristics of the site, and the thermal agitation. It is given by:

$$f_{hkl}^i = D_{DW}^i A_{hkl}^i \eta^i. \quad (5)$$

The  $\eta^i$  parameter is the percentage of the  $i$  site and  $D_{DW}^i$  is a Debye–Waller type factor including thermal agitation and static displacements (due to crystalline defects) the statistics of which is gaussian. Its expression is:

$$D_{DW}^i = \exp(-M_{hkl}^i) \\ = \exp(-2\pi^2 \sigma^2 / d_{hkl}^2) = \exp(-B^i / 4d_{hkl}^2).$$

The  $A_{hkl}^i$  factor is a geometrical factor which is introduced when a site is asymmetrical.

## II. EXPERIMENTAL ARRANGEMENT

### A. Two-axis spectrometer

The experimental setup, installed at the beam line D25B-DCI of the LURE (Orsay) is a double-crystal spectrometer with horizontal axes to preserve the polarization properties of the synchrotron radiation. This double spectrometer consists of two goniometric holders: the first one with the monochromator and the second one with the microrotation device and the sample. The reflectivity is measured by means of a scintillation counter (NaI crystal). The fluorescence is detected with a Si(Li) solid state detector. The angular positioning of the sample and its measurement is achieved by means of an electronic feedback loop between the rotation device (a lever arm rotated with a piezoelectric transducer)

In the case of one atom position, the coherent position is equal to  $d_s/d_{hkl}$ , where  $d_s$  is the position of the atom relative to the diffracting planes and  $d_{hkl}$  the diffracting plane spacing. In the general case of several atomic sites,  $F_{hkl}$  and  $P_{hkl}$  are given by:

and the measurement device (a linear capacitive sensor). The dynamic angular precision is better than 0.01 arcsec. Long term thermal drifts (typically 1 arcsec per hour) are estimated and corrected by periodically recording rapid rocking curves. An experiment consists of several tens of step by step scans through the rocking curve angular domain. The entire setup is controlled by a microcomputer and an integrated software, especially designed for XSW tasks (see Ref. 11).

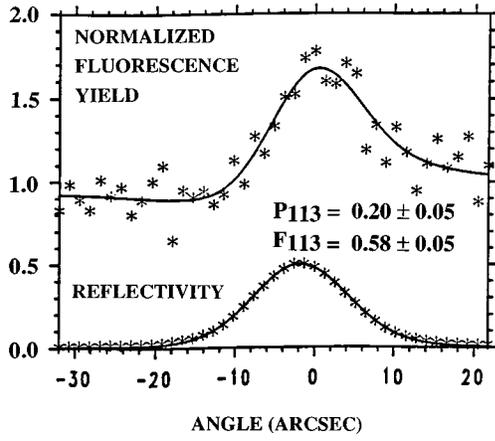
### B. Analysis of data

Data consist of two sets of arrays (one for fluorescence and one for reflection curve) of several scans. The first array contains the rocking curves and the second one the integrated fluorescence signals from three regions of interest: the first region is the fluorescence peak, the two others, located on each side of the peak, allow the determination of the background which is then subtracted. The rocking curves are checked and then added and corrected for the intensity decrease. We proceed in the same manner for the fluorescence data. After normalization, the final curves can be fitted. In order to take into account the intrinsic instrumental function, imperfections of the sample and/or of the monochromator, the calculated rocking curves are convoluted with a gaussian curve which is also used for the fit of the fluorescence curve.

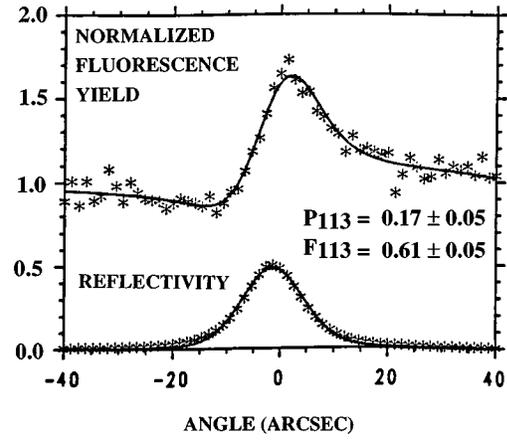
### C. Monochromators

In order to record precise data, the x-ray incident beam must provide a beam with an angular divergence smaller than the studied rocking curve width and with low harmonic contamination. In order to minimize dispersion, we choose a monochromator such that the distance between its diffracting planes,  $d_{h'k'l'}$ , is equal or close to the distance,  $d_{hkl}$ , of the studied reflection on the sample.

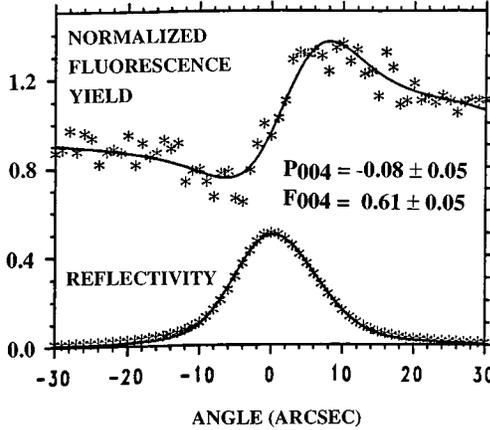
Two monolithic grooved four-reflection monochromators have been used in this study: the first, the second, and the fourth reflections are symmetric, the third one is asymmetric (the principles of this type of monochromator have been previously described in Ref. 11). The first monochromator uses Ge311. Its asymmetry angle for the third reflection is,  $\alpha = 16^\circ$ . The second monochromator uses Si220 with  $\alpha = 10^\circ$  for the third asymmetric reflection. The Ge311 delivers a beam with a wavelength near 1.7 Å: the 933 harmonic is not detectable. The wavelength of the Si220 has been chosen smaller, around 1.2 Å.



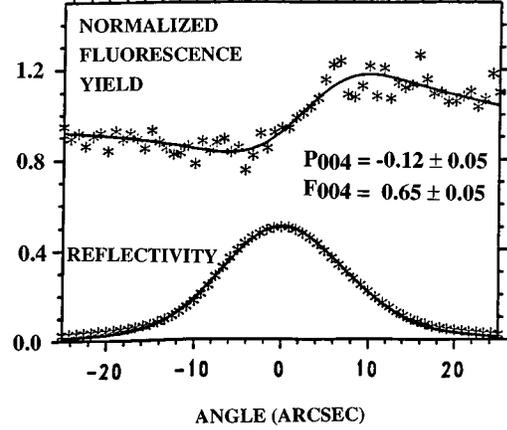
(A)



(C)



(B)



(D)

## D. Sample features

Studied samples consist of CdTe-MnTe heterostructures grown by molecular beam epitaxy on 5 mm square, well-oriented [ $\pm 0.3^\circ$  from (001)], CdTe substrates. They were etched and de-oxidized in a Br-methanol solution and loaded under dry nitrogen into the epitaxy chamber where they were annealed at  $340^\circ\text{C}$  under a Cd flux. A CdTe buffer layer ( $\sim 1000 \text{ \AA}$ ) was then deposited at  $340^\circ\text{C}$  under Cd-rich flux in order to smooth the surface. Then 5 monolayers (MLs) of CdTe were grown at  $320^\circ\text{C}$ , followed by the MnTe thin layer grown at the same temperature ( $320^\circ\text{C}$ ) under slightly Te-rich conditions. Finally, a  $50\text{-\AA}$ -thick CdTe cap layer was grown.

The space group of CdTe is  $F\bar{4}3m$ ; it crystallizes in the zinc-blende (sphalerite) structure, with a cell parameter,  $a_0$ , equal to  $6.481 \text{ \AA}$ . Bulk MnTe has the NiAs structure (hexagonal), but, when deposited on CdTe (001), the MnTe has the same structure as CdTe, with a lattice parameter, as extrapolated from bulk  $\text{Cd}_{1-x}\text{Mn}_x\text{Te}$  (Ref. 12) or measured on thick layers, equal to  $6.34 \text{ \AA}$ .

Two samples have been studied: 0.7 ML of MnTe was deposited on sample No. 1, and 2 ML on sample No. 2. These MnTe coverages are deduced from calibrations of the growth rate of thick MnTe layers as measured by the frequency of reflectivity high energy electron diffraction (RHEED) intensity oscillations, monitored immediately be-

fore the growth of the two samples and in the same conditions. From previous studies, the precision is better than 10%.

## III. RESULTS

### A. Experimental conditions

Two sets of experiments were performed on each sample: the first experiment used the Ge311 monochromator ( $\lambda = 1.702 \text{ \AA}$ ) and the CdTe004 symmetrical reflection. The second experiment (performed several weeks later) used the Si220 monochromator ( $\lambda = 1.113 \text{ \AA}$ ,  $\lambda = 1.244 \text{ \AA}$ ,  $\lambda = 1.273 \text{ \AA}$ ) and the CdTe113 symmetrical tilted reflection. For the 113 reflection, additional experiments have been performed after a  $180^\circ$  rotation of the samples: these 113 and  $\bar{1}13$  reflections had been studied in order to detect a possible asymmetry of the surface.

Before XSW study, topography experiments were performed. For both samples, we get the same type of pictures showing that the crystal is bent and that inhomogeneities are present. For XSW studies, we selected parts of the samples that are as homogeneous as possible. Since the disorder is taken into account in our data analysis by a gaussian curve, we chose parts of the sample with symmetric experimental rocking curves. The size of the selected parts is typically equal to a quarter of the sample surfaces. Note that better

TABLE I.  $F_{hkl}$  and  $P_{hkl}$  parameters extracted from XSW data.

	$P_{004}$	$P_{113}$	$F_{004}$	$F_{113}$
Sample No. 1 0.7 ML	$-0.08 \pm 0.02$	$0.20 \pm 0.02$	$0.61 \pm 0.05$	$0.58 \pm 0.05$
Sample No. 2 2.0 ML	$-0.12 \pm 0.02$	$0.17 \pm 0.02$	$0.65 \pm 0.05$	$0.61 \pm 0.05$

rocking curves and topographies are usually obtained with  $\text{Cd}_{0.96}\text{Zn}_{0.04}\text{Te}$  substrates: here we chose pure CdTe substrates in order to have simpler heterostructures (nominally they contain only pure CdTe and MnTe).

## B. XSW results

Two 004 and two 113 XSW experiments were performed on sample No. 1. Three 004 and three 113 experiments were performed on sample No. 2. Examples of results and fits are given in Fig. 1. No difference has been detected between 113 and  $\bar{1}\bar{1}\bar{3}$  results. The average  $P_{hkl}$  and  $F_{hkl}$  experimental values are shown in Table I.

It may be pointed out that, for the 004 reflection, the Cd and Te atom positions are in the diffracting planes but, for the 113 reflection, there are two different atomic positions, hereafter called up and down, and the diffracting planes run near the middle of these atomic positions (Fig. 2). A  $\pi/2$  rotation around the [001] axis inverts these positions: if we have, for example, Cd atoms at the up position for (113), they occupy the down position for ( $\bar{1}\bar{1}\bar{3}$ ). For a given CdTe crystal and an 113 reflection, three cases might be considered: the first is when the Cd atoms occupy the up positions (and the Te atoms the down positions, consequently), the second when the Cd atoms occupy the down positions and the third when the crystal is of poor quality and exhibits the two preceding cases simultaneously (antiphase domains). Moreover, when 113 XSW results are analyzed, another point is the choice of the origin for the  $P_{hkl}$  value. Three pertinent origins might be chosen; there are the up or the

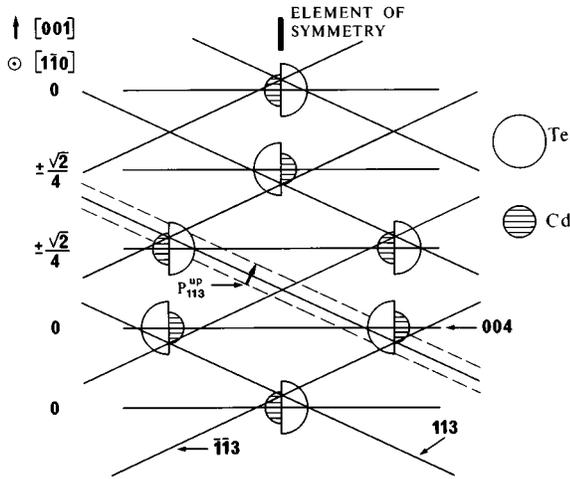


FIG. 2. Schematic illustration of a CdTe (001) surface. Side view along [110]. Geometrical representation of  $P_{113}^{\text{up}}$ . On the left size, the positions along [110] are reported.

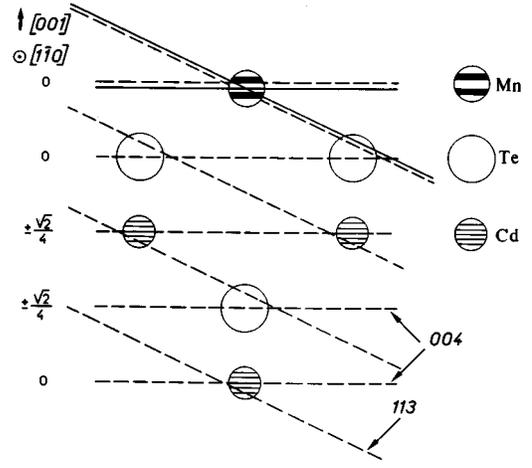


FIG. 3. Schematic representation of Mn average position (sample No. 1) deduced from the  $P_{113}$  and  $P_{004}$  experimental values. solid lines: Mn position. Dashed lines: Cd or Te lattice position.

down positions or the one amidst both these positions. We have chosen the down position as origin of the 113 reflection experiments. So we get (for atoms of the bulk substrate)  $P_{113}^{\text{down}}=0$  and  $P_{113}^{\text{up}}=0.25$  (Fig. 2). Both cases,  $\text{Cd}_{\text{up}}-\text{Te}_{\text{down}}$  and  $\text{Cd}_{\text{down}}-\text{Te}_{\text{up}}$  have been considered in the analysis of the data since the position of diffracting planes changes. The fitted  $P_{113}$  value variation, from one case to the other, is approximately equal to 0.025. The calculated Mn atom positions have always been found near the up position. Since in MnTe, the Mn atoms occupy the same sites as the Cd ones we conclude that the samples are of the  $\text{Cd}_{\text{up}}-\text{Te}_{\text{down}}$  case (Fig. 3) (see the complete demonstration in Sec. IV A 1).

## IV. DISCUSSION

In Sec. IV A we assume that the interface is abrupt with a layer-by-layer growth of pure MnTe on CdTe, and vice-versa. In a first step the experimental distances will be compared with theoretical values (Sec. IV A 1) and the agreement between the different  $P_{hkl}$  (and the corresponding  $D_{hkl}$ ) values will be checked. In a second step, the  $F_{hkl}$  values will be analyzed (Sec. IV A 2). In Sec. IV B, in order to explain the rather low  $F_{004}$  values, models of nonabrupt interfaces, implying diffusion and/or terrace nucleation, will be tested.

### A. Abrupt interface model

#### 1. Elastic model of MnTe: Analysis of $P_{hkl}$ parameters

We first evaluate the distance  $P_{004}$  that we might detect with usual simple models. For coherent growth of the epitaxial MnTe layer on CdTe,<sup>9</sup> the MnTe has the same lateral lattice parameter as bulk CdTe, hence the layer has an in-plane isotropic strain equal to  $\epsilon_{xx} = \epsilon_{yy} = (a_0^{\text{CdTe}} - a_0^{\text{MnTe}})/a_0^{\text{MnTe}} = 2.22 \times 10^{-2}$  ( $a_0^{\text{CdTe}}$  and  $a_0^{\text{MnTe}}$  are the fcc lattice parameters). We may now estimate the vertical [001] component of one MnTe buried layer. For several layers, the classical elastic model might be used without any hesitation. Although this model might be questioned for a single monolayer, we may use it in order to get upper esti-

mation of the  $P_{004}$  parameter. The stress being null perpendicular to the surface we have  $\sigma_{zz}=0=c_{11}\epsilon_{zz}+c_{12}\epsilon_{xx}+c_{12}\epsilon_{yy}$ , from which we get:

$$\epsilon_{zz} = -2 \frac{c_{12}}{c_{11}} \frac{a_0^{\text{CdTe}} - a_0^{\text{MnTe}}}{a_0^{\text{MnTe}}}.$$

The MnTe compliance coefficients are not known but those of CdTe and  $\text{Cd}_{0.5}\text{Mn}_{0.5}\text{Te}$  (See Ref. 13) have been measured and it has been found that the  $c_{12}/c_{11}$  ratio does not significantly vary. The Mn position along the vertical  $z$  axis (here parallel to [001]) with the origin on the diffracting planes, in comparison with the Cd one is then:

$$\begin{aligned} d^{\text{Mn}} &= d_0^{\text{MnTe}}(1 + \epsilon_{zz}) \\ &= d_0^{\text{CdTe}} \left( 1 + \frac{d_0^{\text{MnTe}} - d_0^{\text{CdTe}}}{d_0^{\text{CdTe}}} \right) \\ &\quad \times (1 + \epsilon_{zz}) \approx d_0^{\text{CdTe}} \left[ 1 - \frac{a_0^{\text{CdTe}} - a_0^{\text{MnTe}}}{a_0^{\text{MnTe}}} \left( 1 + 2 \frac{c_{12}}{c_{11}} \right) \right] \\ &= 0.95d^{\text{Cd}}, \end{aligned}$$

where  $d_0^{\text{MnTe}} = a_0^{\text{MnTe}}/4$  and  $d_0^{\text{CdTe}} = a_0^{\text{CdTe}}/4$ . So, the  $D_{004}$  value is here equal to 0.95 (and  $P_{004} = -0.05$ ).

Another model, which has been suggested for thin InAs layers in GaAs,<sup>14</sup> is based on the hypothesis that the buried MnTe layer has the same behavior as in a homogeneous alloy. In other words the Mn–Te bond is constant in length but can rotate. We get:

$$d^{\text{Mn}} = \left( -\frac{(a_0^{\text{CdTe}})^2}{8} + 3 \frac{(a_0^{\text{MnTe}})^2}{16} \right)^{1/2} \approx 0.934d^{\text{Cd}}.$$

Here,  $D_{004} = 0.934$  and  $P_{004} = -0.066$ .

In sample No. 1, the experimental  $D_{004}$  experimental value, equal to  $0.92 \pm 0.02$  ( $P_{004} = -0.08 \pm 0.02$ ), is a little low but seems in quite good agreement with the value of the second model.

Concerning sample No. 2, we can estimate the 004 Mn distance from its experimental  $P_{004}$  value in the hypothesis that there are two perfectly organized layers with the same spacing (and the same Debye–Waller factor). Let us define  $P_{hkl}^i$  the coherent position of the  $i$ th monolayer. The position of a second layer is given by  $P_{004}^2 = 3P_{004}^1$ . From the experimental value,  $P_{004} = -0.12$  (which is an average over the two monolayers) we get  $P_{004}^1 = -0.06 \pm 0.01$ . This last value would be in very good agreement with the second model.

Additional information may be obtained when comparing the  $P_{004}$  and  $P_{113}$  results for each sample. We have pointed out that 113 XSW is sensitive to the fact that there are two atomic sites, labeled up and down in Fig. 3. If we assume that the Mn atoms sit only at the up positions (which will have to be ascribed to the Cd site), then the site is on an axis of symmetry and we can relate the  $P_{113}$  value to the  $P_{004}$  one. With the  $P_{113}$  origin on the down position, we obtain:

$$P_{113} = P_{113}^{\text{up}} + [\cos(\theta)d_{004}/d_{113}]P_{004}, \quad (6)$$

where  $\theta = 25.24^\circ$  is the angle between the [001] and [113] directions. So we get:

$$P_{113} = P_{113}^{\text{up}} + 0.75P_{004} \quad (\text{here } P_{004} \text{ is negative}).$$

For sample No. 1 we calculate  $P_{113} = 0.19$  (from the experimental  $P_{004}$ ) and we measure  $P_{113} = 0.20 \pm 0.02$  (Fig. 3). In the same manner, for sample No. 2 we calculate  $P_{113} = 0.157$  and measure  $P_{113} = 0.170 \pm 0.02$ .

This agreement shows that there is no presence of Mn atoms on the down sites (“antisites”). One can notice that a mixing of 113 up and down positions for Mn would give a  $P_{hkl}$  intersection out of the axis of symmetry (Fig. 2). The  $P_{004}$  would be insensitive to the up and down position mixing but the 113 experiment would detect two positions: the presence of  $\text{Mn}_{\text{down}}$  would decrease the  $P_{113}$  value and the triangulation of the  $P_{hkl}$  would give a point out of the axis of symmetry.

## 2. Analysis of the $F_{hkl}$ parameters

We will now discuss the  $F_{113}$  and  $F_{004}$  values of each sample. Let us remember that the  $F_{hkl}$  parameters [formula (3) and (5)] depend on the  $P_{hkl}^i$  positions of Mn atoms, on the random static disorder ( $1 - D_{\text{DS}}$ ), and on parameters  $f_{hkl}^i = D_{\text{DW}}^i A_{hkl}^i \eta^i$ , where  $D_{\text{DW}}^i$  is a Debye–Waller type factor,  $\eta^i$  the percentage of atoms at site  $i$ , and  $A_{hkl}^i$ , a geometrical factor, taking into account the asymmetry of site  $i$ . It is readily seen that a discussion of  $F_{hkl}$  values needs more hypotheses than one about the  $P_{hkl}$  values. We first assume that the random static disorder is negligible. Indeed HRTEM experiments on similarly grown MnTe buried layers<sup>9</sup> have not detected any significant rate of faults which could explain a significant value of the random static disorder. We will also assume that the asymmetry of the site is not important (i.e.,  $A_{hkl}^i \approx 1$ ) and can be included in the Debye–Waller factor: the distortion from symmetry might be estimated to be close to the parameter misfits as suggested by the work of Balzarotti *et al.*<sup>12</sup> on  $\text{Cd}_{1-x}\text{Mn}_x\text{Te}$  alloy. Moreover, since the  $P_{hkl}$  are more or less compatible with 1 ML on sample No. 1 and 2 ML on sample No. 2 we will not consider, in a first step, the presence of parts of additional layers. Then the coherent fraction is reduced to the Debye–Waller factor (which is supposed to be isotropic) for sample 1, and depends on the Debye–Waller factor and the coherent positions for sample 2.

The maximum value of the Debye–Waller factor might be estimated under the hypothesis that the Mn thermal vibrations are close to the ones of the Cd atoms in the CdTe substrate. Since we have  $B^{\text{Cd}} = 1.71$ ,<sup>15</sup> the calculated Debye–Waller factor are  $e^{-M^{\text{Cd}}004} = 0.85$  and  $e^{-M^{\text{Cd}}113} = 0.89$ . We will first discuss the  $F_{004}$ . It is readily seen that the experimental value on sample 1 ( $0.61 \pm 0.05$ ) is much lower than the above estimated Debye–Waller factor. Considering sample number 2 we can extract the Debye–Waller factor if we take into account the fact that there are two monolayers [formula (3)]. With  $P_{004}^1 = -0.066$ , we get  $e^{-M^{\text{Cd}}004} = F_{004}/0.925 = 0.70 \pm 0.06$ , which is smaller than the value calculated for thermal vibrations. Such a low value has been already reported for adsorbate structures (see Ref. 16 and references therein, for example) but seems difficult to justify for our buried layers. Concerning the  $F_{113}$  values one can

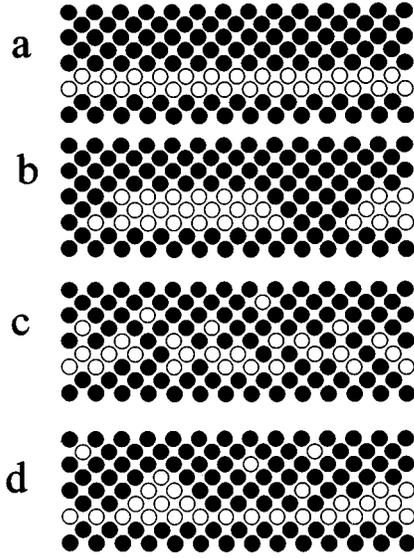


FIG. 4. Schematic of the models used for the 2 ML sample (No. 2), (a) ideal 2 ML, (b) islands, (c) alloy, (d) mixed (open circles: Mn, solid: Cd).

expect that their value must be higher, since  $d_{113}$  is greater than  $d_{004}$ . It is not the case and so a higher lateral disorder is evidenced.

In conclusion it is readily seen that the hypothesis of perfect MnTe layers, which accounts for the measured  $P_{hkl}$  values, cannot explain the low  $F_{hkl}$  results without assuming exceedingly large defect densities. In Sec. IV B we will introduce interface models which might explain the experimental  $F_{004}$  values without the recourse to structural defects.

## B. Nonabrupt interface models

In the preceding sections we have discussed our results under the hypothesis that the 0.7 ML sample has only one Mn position (incomplete ideal perfect MnTe monolayer) and the 2 ML sample, two Mn positions (ideal MnTe double monolayer). We will now assume that terrace nucleation and exchange of Cd/Mn atoms across the interface appear during the growth of the MnTe thin layer (Fig. 4). Terrace nucleation is suggested by the observation<sup>9</sup> of a roughness increasing with the thickness of MnTe layers (these layers were thicker than in the present study); the atom exchange was described in  $\text{Cd}_{1-x}\text{Mn}_x\text{Te}$  heterostructures with  $x$  around 0.3.<sup>3</sup> We have first tested two extreme models, one with roughness only and one with dilution only.

### 1. Roughness

In the first model we consider that the Mn is organized in MnTe islands, several monolayers thick. In order to estimate the minimum  $F_{004}$  value we will assume that each layer has the same lateral size (i.e., the same coverage) and that the  $P_{hkl}$  parameter for one perfect layer has the value deduced from the rotation bond model (note however that this is indeed the case where the bulklike elastic model should better apply). Let us call, as above,  $P_{004}^i$  the Mn 004 position of the  $i$ th layer. We have  $P_{004}^i = (2i - 1)P_{004}^1$  and  $P_{004}^1 = -0.066$ . The  $F_{004}$  values, without the Debye–Waller factor, are successively equal to  $F_{004} \cong 0.91$  for two layers,  $F_{004} \cong 0.73$  for

three layers, and  $F_{004} \cong 0.61$  for four layers. We might conclude that a MnTe island model needs at least three layers, but in this case the  $P_{004}$  value ( $P_{004} \cong -0.2$ ) becomes lower than the experimental one and therefore this extreme model must be rejected. Moreover it is easily seen that derived models (with variations of the layer percentages) give equivalent conclusions.

### 2. Dilution

In the second model we assume that there are one or several full layers of  $\text{Cd}_{1-x}\text{Mn}_x\text{Te}$  laterally homogeneous alloy. The value of the lattice parameter is known to vary linearly with  $x$  (Vegard’s law). Hence the insertion of a single monolayer of  $\text{Cd}_{1-x}\text{Mn}_x\text{Te}$  will shift the Mn atoms within this layer by  $xP_{004}^1$ , where  $P_{004}^1$  is the above value in MnTe, and shift the atoms sitting on it by  $2xP_{004}^1$  (this description should hold well for dilute alloys, and probably less for concentrated alloys where the formation of Mn pairs, triads, and larger clusters should introduce some disorder). We see at once that if sample No. 1 actually contain a monolayer of  $\text{Cd}_{0.3}\text{Mn}_{0.7}\text{Te}$  due to a rapid diffusion within the surface layer, we should measure a larger value of  $P_{004}$ ,  $P_{004} = -0.04$ , and  $F_{004}$  close to 1 since it would comprise only the Debye–Waller contribution as in Sec. IV A. Reference 3 suggests that we have several layers of  $\text{Cd}_{1-x}\text{Mn}_x\text{Te}$  alloy, with  $x$  resulting from a complete intermixing, during the growth of the interface, between the (just incorporated) surface layer and the monolayer being grown.  $P_{004}$  and  $F_{004}$  are easily calculated for a given composition profile  $x_i$  and the resulting  $P_{004}^i$ :

$$P_{004}^i = 2 \sum_{j < i} x_j P_{004}^1 + x_i P_{004}^1.$$

If necessary, an integer number has to be added in order to remain in the  $[-0.5, 0.5]$  interval. All reasonable composition profiles (uniform  $x_i$  or profiles from Ref. 3) lead to larger  $P_{004}$  than for the nominal profile (Sec. IV A) and  $F_{004}$  values close to 1.

### 3. Roughness and dilution

From the two preceding models, and from the abrupt interface model, we must conclude that: (a) in the abrupt interface model, the values of  $P_{004}$  are correct but we cannot explain the low  $F_{004}$  values; and (b) the formation of clusters or 3D islands (or roughness) decreases the values of  $P_{004}$  and  $F_{004}$ ; if we assume that all Mn atoms are incorporated in 3D islands, the calculated  $F_{004}$  parameter can be decreased down to the experimental value, but the calculated  $P_{004}$  value is too low; (c) the dilution of MnTe into a  $\text{Cd}_{1-x}\text{Mn}_x\text{Te}$  alloy increases  $P_{004}$ ; if we assume that all Mn atoms are incorporated in laterally homogeneous  $\text{Cd}_{1-x}\text{Mn}_x\text{Te}$  alloy layers, then the calculated  $P_{004}$  parameter is larger than the experimental one, and the  $F_{004}$  is close to 1.

Actually a better agreement can be found by assuming that both islands and alloy coexist [Fig. 4(d)]. We have checked this for sample No. 2 which exhibits a larger  $F_{004}$  value (i.e., better ordering). We assume that the MnTe layer is composed with one complete MnTe monolayer covered

with MnTe pyramidal islands and Mn diluted atoms. For example, the respective area of each layer of the pyramidal island corresponds to the ratio 4:2:1. With a quantity of diluted Mn atoms equivalent to 0.5 ML and pyramidal islands the bases of which occupy 28% of the surface, we get the experimental  $P_{004}$  value ( $P_{004} = -0.12$ ) with  $F_{004} = 0.8$ . This last value agrees with the experimental value corrected from the thermal vibrations ( $F_{004} = 0.765$ ). Similar morphologies (pyramidal MnTe islands *and* diluted Mn atoms) may also account for the 004 experimental values of sample No. 1. Of course the exact morphology of these islands is not known. Moreover, a precise calculation should take into account strain relaxation at the island edges, and the existence of clusters in the alloy.

We may note that such morphologies would agree with both the results of HRTEM on MnTe buried layers,<sup>9</sup> which reveal that roughness tends to increase during the growth of MnTe under Te excess, and those of Zeeman effect of excitons in CdTe-Cd<sub>1-x</sub>Mn<sub>x</sub>Te quantum wells, which reveal that an exponential alloy profile is found when the whole structure, with  $x = 0.2$  to  $0.4$  is grown under Cd excess. Similar Zeeman effects are found for nominally pure MnTe barriers,<sup>17</sup> followed by the growth of a CdTe quantum well, but we have to keep in mind that in this case Zeeman effect of confined excitons tests the existence of an exponential tail of Cd<sub>1-x</sub>Mn<sub>x</sub>Te only in the low concentration part of the sample, i.e., the nominally pure CdTe quantum well grown under Cd excess. Samples entirely grown under Te excess seem to exhibit both rougher interfaces (broader optical lines), and lower Zeeman effects indicating a smaller dilution of Mn into the CdTe quantum well.<sup>18</sup> It is worth noting that while magneto-optics studies are mainly sensitive to the presence of isolated Mn atoms (i.e., the decrease of the number of Mn pairs correlated by nearest-neighbour antiferromagnetic interaction) in the low-concentration part of the sample, on the contrary the present XSW study reveals the presence of MnTe clusters, whatever their shape, in MnTe-CdTe heterostructures.

## V. CONCLUSION

The 004 and 113 XSW study of 0.7 and 2 MnTe monolayers buried in CdTe(001) give coherent position values

which agree with those expected for MnTe coherently strained to CdTe. If we assume perfect interfaces, a slightly better agreement is found if we assume that the strain is accommodated by bond rotation only, than if we apply bulk elastic coefficients. However, the experimental coherent fraction values  $F_{hkl}$  lead suspect that the interfaces are not abrupt. The vertical Mn distribution on the 2 ML sample is compatible with a crude model including one MnTe layer and a mixing of MnTe islands and diluted Mn atoms (CdMnTe alloy). The 0.7 ML sample seems to contain MnTe islands together with CdMnTe alloy.

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